

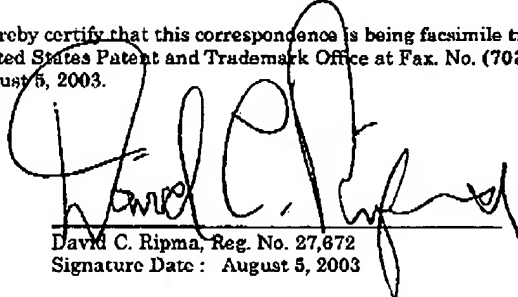
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of) PATENT APPLICATION
)
Inventor: Hirohiko Nishiki, James M.) August 5, 2003
Atkinson, and Yukihiro Nakata)
) ATTORNEY DOCKET
Serial No.: 10/040,646) No. SLA0452
)
Filed: January 7, 2002) Group Art Unit: 1765
)
Title: SYSTEM AND METHOD FOR) Examiner: Anita Karen
ETCHING RESIN WITH AN) Alanko
OZONE WET PROCESS)

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8/7/03
1765
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GROUP 1700

CERTIFICATE OF TRANSMITTAL UNDER 37 C.F.R. § 1.8

I hereby certify that this correspondence is being facsimile transmitted to the United States Patent and Trademark Office at Fax. No. (703) 872-9810 on August 5, 2003.


David C. Ripma, Reg. No. 27,672
Signature Date: August 5, 2003

RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Non-Fee Amendment
Hon. Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This communication responds to an Office Action dated July 30, 2003 in the above-identified patent application.

In the Office Action the Examiner requires restriction to one of the following inventions:

Group I. Claims 1-8 and 20, drawn to a method for cleaning
a resin residue; and

Group II. Claims 9-19, drawn to a method for repairing a
resin interlayer surface.

Applicants hereby elect to pursue the Group I claims, claims 1-8
and 20.

Date: 8/5/03

Respectfully submitted,

By: 

David C. Ripma,
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